New 371 U.S. National Stage Appln Of PCT/JP2005/016808

Docket No. 034145.004

## IN THE CLAIMS

Please amend the claims as follows:

[7] (Currently Amended) A transparent onductive film according to any one of claims 1-

6 claims 1 or 2, wherein the metallic thin film ranges in thickness from 1 nm to 20 nm.

[12] (Currently Amended) A transparent conductive film according to any one of claims

1-11 claims 1 or 2, wherein a transmittance of light with a wavelength of 380 nm in a film

itself is more than 80 %.

[13] (Currently Amended) A transparent conductive film according to any one of claims

1-12 claims 1 or 2, wherein a transmittance of light with a wavelength of 320 nm in a film

itself is more than 62 %.

[14] (Currently Amended) A transparent conductive film according to any one of claims

1-13 claims 1 or 2, wherein a transmittance of light with a wavelength of 300 nm in a film

itself is more than 56 %.

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- [15] (Currently Amended) A transparent conductive film according to any one of claims 1—14 claims 1 or 2, wherein a surface resistance is less than 20  $\Omega$  /  $\Box$ .
- [16] (Currently Amended) A transparent conductive base material comprising a transparent conductive film according to any one of claims 1-15 claim 1 or 2, formed on one or each surface of a transparent substrate of one selected from materials such as a glass plate, a quartz plate, a resin plate or resin film, one or each surface of which is coated with a gas barrier film, and a resin plate or resin film into which the gas barrier film is inserted.
- [20] (Currently Amended) A transparent conductive base material according to any one of claims 16-19 16-18, wherein a transmittance of light with a wavelength of 320 nm is more than 65 %.
- [21] (Currently Amended) In the transparent conductive base material according to any one of claims 16-20 16-18, wherein a transmittance of light with a wavelength of 300 nm is more than 60 %.

[22] (Currently Amended) A transparent conductive base material according to any one of claims  $\frac{16-21}{16-18}$ , wherein a surface resistance is less than 20  $\Omega$  /  $\Box$ .

[24] (Currently Amended) A light-emitting device in which a transparent conductive film according to any one of claims 1-15 claims 1 or 2 is used for a transparent electrode.